ORIGINALLY FILED	L			Com	piete ii Kilowii		
FEE TRANSMITTAL SHEET (FOR FY 2001)	Application No. 09/652,579						
	Filing Date		August 31, 2000				
	First Named Inventor		Vishnu K. Agarwal				
WE 8 TOOL STORE TO LOUIS		Group Art Unit		2825		<i>1</i> 2.	
		Examiner			Caridad M. Everhart		
		Atty. Docket Number			501082.14 (98-0616.13)		
METHOD OF PAYMENT (Check One)			F	EE CALC	ULATION (Continued)	٠, ۲	
The Commissioner is hereby authorized to charge any		3. ADDITIONAL FEES					
additional fee required under 37 C.F.R. §§ 1.16 and 1.17 and	Large Er	-	Small I	-	ر الم	,	
1.136(a)(3) and credit any over payments to Deposit Account No.: 50-1266; Deposit Account Name: DORSEY & WHITNEY LLP	Fee Code	Fee (\$)	Fee Code	Fee (\$)	Fee Description	Fee paid	
140 304 200, Deposit Account Name. Dortog a VVIII Me y gg.	105	130	205	65	Surcharge - Late filing fee or oath	G 8	
2. Check Enclosed	127	50	227	25	Surcharge - late provisional filing fee or cover sheet		
FEE CALCULATION	139	130	139	130	Non-English specification	\$	
1. BASIC FILING FEE	147	2,520	147	2,520	For Filing a Request for Reexamination	\$	
Large Entity Small Entity Fee Fee Fee Fee Fee Fee Fee Fee Fee	195	300	196	300	Publication (early or Republication)	\$	
Code (\$) Code (\$)	115	110	215	55	Extension for reply within first month	\$	
101 740 201 370 [] Utility Filing Fee	118	400	216	200	Extension for reply within 2 nd month	\$	
106 330 206 165 ∏ Design Filing Fee	117	920	217	460	Extension for reply within 3 rd month		
100 330 200 100 Design Filling Fee	11,8	1,440	218	720	Extension for reply within 4 th month	\$	
108 740 208 370 [] Reissue Filing Fee	128	1,960	- 280	980	Extension for reply within 5 th month		
114 160 214 80 Provisional Filing Fc	120		220	160	Filing a brief in support of an appeal —		
Subtotal (1) \$0	121	280	270	140	Request for oral hearing	<u> </u>	
	148	110	248	55 55	Terminal Disclaimer Fee Petition to revive – unavoidable		
2. EXTRA CLAIM FEES Current Claims Prior Extra Fee Fee Paid	140	110	240	640	Petition to revive – unintentional	5	
Total 6 - 20 = 0 x \$ = \$0	1 2	1,280	242	640	Utility/Reissue issue fee (+ advance	\$	
Ind. 2 - 3 = 0 x \$: \$0	167	460	243	i.	copies) Design issue fee (+ advance copies)		
IMultiple Dependent Claims x \$ = \$	122	130	122	130	Petitions to the Commissioner	\$	
Subtotal (2) 50	123	50	123	50	Petitions related to provisional applications	\$	
Large Entity Small Entity	126	180	126	180	Submission of IDS	\$	
Fee Fee Fee Fee Fee Description Code (\$) Code (\$)	581	40	81	40	Recording each patent assignment per property (times number of properties)	\$	
103 18 203 9 Claims in excess of 20	179	740	279	370	Request for Continued Examination (RCE)	\$	
102 84 202 42 Independent claims in excess of 3	Other fe	e (spe	cify)			5	
104 280 204 140 Multiple dependent Claim Reissue independent claims over					Subtotal (3)	\$0	
109 80 209 40 reissate interpretation of 30 original patent 110 18 210 9 Reissue claims in excess of 20 and				-	Total Amount of Payment:	\$0	
over original palent							
Submitted by:				-			
Name: Paul F. Rusya. Reg. No.: 42,118	1		1	Felephon	e: (206) 903-8800		

Signature:

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Date:

COPY OF PAPERS ORIGINALLY FILED **PATENT**

n the date specified below, this correspondence is being deposited with the United States Postal Service as first-class mail in an envelope addressed to Box Non-Fee Amendment, Commissioner of Patents, Washington, DC 20231.

Ayesha S. Wilks

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Vishnu K. Agarwal

Attorney Docket No.: 501082.14 (98-0616.13)

Serial No. : 09/652,579

Group Art Unit

: 2825

Filed

: August 31, 2000

Examiner

: Caridad M. Everhart

Title

: DEVICE AND METHOD FOR PROTECTING AGAINST OXIDATION OF A

CONDUCTIVE LAYER IN SAID DEVICE

Box Non-Fee Amendment Commissioner of Patents Washington, DC 20231

AMENDMENT

Sir:

Please amend the above-captioned patent application as follows:

In the Claims:

Please cancel claims 45 and 46.

Please amend claims 47 and 48 as follows:

A method of treating a wafer, comprising: 47. (Amended)

depositing a first conductive layer onto the wafer;

exposing the wafer in situ to a reducing environment; and

depositing a second conductive layer; and

exposing/said wafer in situ to an N2/H2 plasma prior to said step

of depositing a second conductive layer.